## PATENT ABSTRACTS OF JAPAN

(11)Publication number:

2001-031671

(43) Date of publication of application: 06.02.2001

(51)Int.CI.

C07D317/22 B01J 23/44 C07D319/06 // C07B 61/00

(21)Application number: 11-201497

(71)Applicant: KAO CORP

(22)Date of filing:

15.07.1999

(72)Inventor: FUJII YASUYUKI

YANO SHINJI KITA KATSUMI

## (54) PRODUCTION OF ETHER ACETAL

))Abstract:

PROBLEM TO BE SOLVED: To provide a method for producing an ether acetal in high yield with a simple operation without requiring to use an organic halogen compound and without generating a large amount of salts as by-products.

SOLUTION: This production of an ether acetal is to produce a compound having ether and acetal skeletons in one pot by reacting a polyhydric alcohol having ≥3 hydroxy groups with a carbonyl compound under a hydrogen atmosphere having normal to 2 MPa hydrogen pressure in the presence of a palladiumbased catalyst at 10–200° C. During the reaction, operations for flowing hydrogen and dropping the carbonyl compound are preferably included.

## **LEGAL STATUS**

[Date of request for examination]

[Date of sending the examiner's decision of rejection]

[Kind of final disposal of application other than the aminer's decision of rejection or application converted registration]

[Date of final disposal for application]

[Patent number]

[Date of registration]

[Number of appeal against examiner's decision of rejection]

[Date of requesting appeal against examiner's decision of rejection]

[Date of extinction of right]

Copyright (C): 1998,2003 Japan Patent Office